

IFW



PATENT
8074-1143

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Koichi NANIWAE Conf. 9283

Application No. 10/573,492 Group 2892

Filed May 15, 2006 Examiner E. Jones

METHOD OF CLEANING TREATMENT AND
METHOD FOR MANUFACTURING SEMICONDUCTOR
DEVICE

AMENDMENT

Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

April 30, 2008

Sir:

In response to the Official Action mailed April 1, 2008, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 11 of this paper.